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UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Hitoshi ASADA et al.

Serial No.: **09/753,616**

Group Art Unit: **2811**

Filed: **January 4, 2001**

Examiner: **GEBREMARIAM, S.**

For: **CMOS IMAGE SENSOR AND MANUFACTURING METHOD OF THE SAME**

**RESPONSE TO THE RESTRICTION REQUIREMENT
DATED JANUARY 28, 2002**

Commissioner for Patents
Washington, D.C. 20231

Date: February 19, 2002

Sir:

This paper is submitted in response to the Official Action dated January 28, 2002.

In the Action, restriction is required between Group (I), Claims 1-6, drawn to semiconductor integrated circuit device; and Group (II), Claims 7-13, drawn to a method of forming integrated circuit device.

Applicants hereby elect the subject matter of Group (I), Claims 1-6 for prosecution in this application. This election is made without traverse, it being understood that the applicants' rights to the filing of a divisional application directed to the non-elected subject matter under 35 USC 120 and 35 USC 121 are retained.

In the event that this paper is not timely filed, applicants hereby petition for an appropriate extension of time. The fee for any such extension may be charged to our Deposit Account No. 01-2340.

In the event any additional fees are required in connection with this response, please charge
our Deposit Account No. 01-2340.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

A handwritten signature in black ink, appearing to read 'W. Kratz, Jr.', written over the printed name.

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